

Andrey P Kokhanenko

List of Publications by Year in descending order

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Version: 2024-02-01

19
papers

218
citations

933447

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996975

15
g-index

19
all docs

19
docs citations

19
times ranked

148
citing authors

#	ARTICLE	IF	CITATIONS
1	Kinetics of epitaxial formation of nanostructures by Frank-van der Merwe, Volmer-Weber and Stranski-Krastanow growth modes. <i>Surface and Coatings Technology</i> , 2020, 384, 125289.	4.8	52
2	Generalized Muller-Kern formula for equilibrium thickness of a wetting layer with respect to the dependence of the surface energy of island facets on the thickness of the 2D layer. <i>Physical Chemistry Chemical Physics</i> , 2015, 17, 30052-30056.	2.8	17
3	Comparative analysis of germanium-silicon quantum dots formation on Si(100), Si(111) and Sn/Si(100) surfaces. <i>Nanotechnology</i> , 2018, 29, 054002.	2.6	16
4	Epitaxial fabrication of 2D materials of group IV elements. <i>Applied Nanoscience (Switzerland)</i> , 2020, 10, 4375-4383.	3.1	15
5	Single-Element 2D Materials beyond Graphene: Methods of Epitaxial Synthesis. <i>Nanomaterials</i> , 2022, 12, 2221.	4.1	15
6	Influence of Edge Energy on Modeling the Growth Kinetics of Quantum Dots. <i>Crystal Growth and Design</i> , 2015, 15, 1055-1059.	3.0	14
7	Comparative analysis of pyramidal and wedge-like quantum dots formation kinetics in Ge/Si(001) system. <i>Surface Science</i> , 2014, 619, 1-4.	1.9	13
8	Critical thickness of transition from 2D to 3D growth and peculiarities of quantum dots formation in Ge Si1-/Sn/Si and Ge1-ySny/Si systems. <i>Surface Science</i> , 2018, 669, 45-49.	1.9	13
9	Single-photon avalanche diode detectors based on group IV materials. <i>Applied Nanoscience (Switzerland)</i> , 2022, 12, 253-263.	3.1	13
10	Evolution of Epitaxial Quantum Dots Formed by Volmer-Weber Growth Mechanism. <i>Crystal Growth and Design</i> , 2019, 19, 7015-7021.	3.0	11
11	Molecular dynamics simulations of the growth of Ge on Si. <i>Surface Science</i> , 2020, 696, 121594.	1.9	10
12	Thickness-dependent elastic strain in Stranski-Krastanow growth. <i>Physical Chemistry Chemical Physics</i> , 2020, 22, 19318-19325.	2.8	9
13	Thickness-dependent surface energy and formation of epitaxial quantum dots. <i>Thin Solid Films</i> , 2020, 713, 138363.	1.8	7
14	Interaction between islands in kinetic models of epitaxial growth of quantum dots. <i>Applied Nanoscience (Switzerland)</i> , 2020, 10, 2527-2533.	3.1	6
15	High-resolution RHEED analysis of dynamics of low-temperature superstructure transitions in Ge/Si(001) epitaxial system. <i>Nanotechnology</i> , 2022, 33, 115603.	2.6	5
16	Photodetectors and solar cells with Ge/Si quantum dots parameters dependence on growth conditions. <i>International Journal of Nanotechnology</i> , 2015, 12, 209.	0.2	2
17	Investigation of Ge/Si quantum dot structures using the methods of admittance spectroscopy. <i>International Journal of Nanotechnology</i> , 2015, 12, 285.	0.2	0
18	Influence of Direct Impingement of Atoms Onto the Islands During the Stranski-Krastanow Growth. , 2018, , .		0

#	ARTICLE	IF	CITATIONS
19	USE OF THE COMPETENCY AND MODULAR APPROACHES TO THE ORGANIZATION OF THE LABORATORY WORKSHOP FOR STUDENTS OF DIFFERENT LEVELS OF TRAINING. Vestnik Tomskogo Gosudarstvennogo Universiteta, 2015, , 220-224.	0.1	0